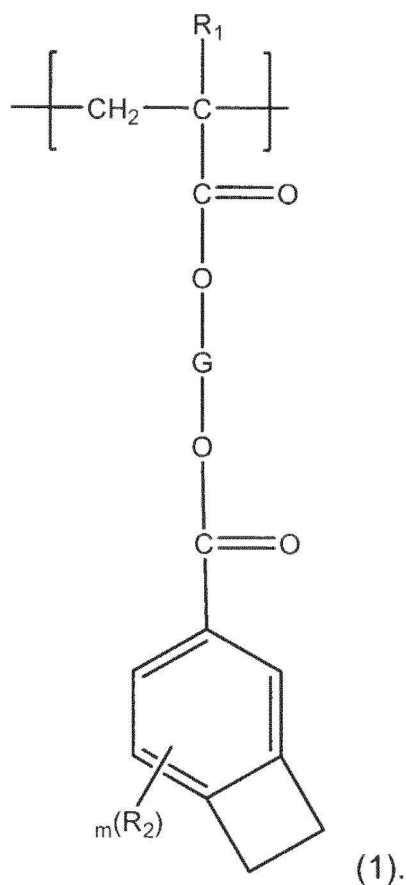


Abstract

POLYMER COMPOSITIONS FOR SELF-ASSEMBLY APPLICATIONS

The present invention relates to a composition comprises at least one random copolymer having at least one repeat unit of structure (1), The present invention also relates to novel processes for forming patterns using this novel crosslinked layer on a substrate by enable a film of a block copolymer coated on the novel crosslinked layer to undergo self-assembly.



[NO SUITABLE FIGURE]